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The invention refers to the optical information supports and may be used in holography, micro- and optoelectronics computer engineering.

Supports for optical images and holographic information registration contains an electric conductive substrate 1, on which there are subsequently applied a photosensitive injector layer 3, a registration layer 4 and an upper metallic electrode 5. The injection substrate is executed in the form of a thin p -TlSbSe₂ compound forming in contact to the electric conductive substrate 1, consisting of SnO₂, a p - n -heterojunction. By that, the injector and registration substrates $3L_1$ and $4L_2$ thickness is determined by the ratio $2 \leq L_1 / L_2 \leq 5$ at a general thickness of $1,0 \leq L = L_1 + L_2 \leq 3,0 \mu\text{m}$.

